



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 9635**  
Satoshi MAEMORI et al. : **Attorney Docket No. 2001\_1300A**  
Serial No. 09/955,111 : **Group Art Unit 1752**  
Filed September 19, 2001 : **Examiner Sin J. Lee**  
**POSITIVE-WORKING PHOTORESIST** **Mail Stop: AF**  
**COMPOSITION AND PHOTSENSITIVE**  
**MATERIAL USING SAME**

---

**RESPONSE TO FINAL REJECTION**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Final Rejection dated September 7, 2005, the period for response having been extended for one month by the attached petition, please amend the present application as follows:

Please  
Enter  
SJL  
1-4-06